



STW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q66584

Masayuki NAYA, et al.

Appln. No.: 10/053,585

Group Art Unit: 1641

Confirmation No.: 3648

Examiner: Christopher L. Chin

Filed: January 24, 2002

For: SURFACE PLASMON RESONANCE MEASURING CHIP AND METHOD OF
MANUFACTURE THEREOF

RESPONSE TO RESTRICTION REQUIREMENT

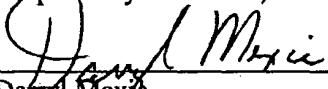
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450
Sir:

In response to the Restriction Requirement, dated September 30, 2004, Applicants elect
Group I, claims 1-12 for examination. This election is made without traverse.

Applicants reserve the right to file a Divisional Application directed to non-elected claim
13.

The USPTO is directed and authorized to charge all required fees, except for the Issue
Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any
overpayments to said Deposit Account.

Respectfully submitted,


Darryl Mexie

Registration No. 23,063

SUGHRUE MION, PLLC
Telephone: (202) 293-7060
Facsimile: (202) 293-7860

WASHINGTON OFFICE

23373

CUSTOMER NUMBER

Date: October 29, 2004